

## Measurement of positron mobility in silicon

This article has been downloaded from IOPscience. Please scroll down to see the full text article.

1990 J. Phys.: Condens. Matter 2 7255

(<http://iopscience.iop.org/0953-8984/2/34/519>)

View [the table of contents for this issue](#), or go to the [journal homepage](#) for more

Download details:

IP Address: 171.66.16.103

The article was downloaded on 11/05/2010 at 06:04

Please note that [terms and conditions apply](#).

## ERRATUM

**Measurement of positron mobility in silicon** by R I Simpson, M G Stewart, C D Beling and M Charlton (*J. Phys.: Condens. Matter* 1989 **1** L7251–7256)

In the above study the electric field in the depletion of the Au–Si–Al samples was calculated incorrectly leading to errors in the reported values of  $\mu_+$ . The correct electric field distribution, derived from Laplace's equation (Sze 1981, Awcock and Young 1963), shows a linear variation across the region, with a maximum field at the Au–Si interface. Since the maximum drift length to the Au–Si interface is  $10\ \mu\text{m}$  the  $e^+$  therefore experience a uniform field approximately equal to that at the interface.

Re-evaluation of the centroid data presented in the letter gives  $\mu_+(295\ \text{K}) = (68 \pm 1)\ \text{cm}^2\ \text{V}^{-1}\ \text{s}^{-1}$ , and, using a fit to the Shockley expression for acoustic phonon limited carrier drift velocity,  $\mu_+(104\ \text{K}) = (370 + 80)\ \text{cm}^2\ \text{V}^{-1}\ \text{s}^{-1}$ . These results are in good agreement with a  $T^{-1.5}$  extrapolation of the data reported by Mills and Pfeiffer (1977). The room temperature value is also in agreement with the estimate of  $\mu_+$  published recently by Corbel *et al* (1989).

A logarithmic fit of the current data and that of Mills and Pfeiffer (1977) gives a value for  $n$ , the temperature coefficient of  $e^+$  mobility in Si, of  $1.3 \pm 0.1$  which is somewhat less than the value of 1.5 expected from the charge carrier–acoustic phonon scattering model. A more detailed theoretical treatment of  $e^+$  motion in Si would therefore be worthwhile.

### References

- Awcock M L and Young D C 1963 *UK AERE Report* R4710  
Corbel C, Hautojärvi P, Makinen J, Vehanen A and Mathiot D 1989 *J. Phys.: Condens. Matter* **1** 6315  
Sze S M 1981 *Physics of Semiconductor Devices* 2nd edn (New York: Wiley)  
Mills A P Jr and Pfeiffer L 1977 *Phys. Lett.* **63A** 118